The neutral silicon-vacancy center in diamond: spin polarization and lifetimes

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We demonstrate optical spin polarization of the neutrally-charged silicon-vacancy defect in diamond (SiV0), an \( S = 1 \) defect which emits with a zero-phonon line at 946 nm. The spin polarization is found to be most efficient under resonant excitation, but non-zero at below-resonant energies. We measure an ensemble spin coherence time \( T_2 > 100 \mu s \) at low-temperature, and a spin relaxation limit of \( T_1 > 25 \text{s} \). Optical spin state initialization around 946 nm allows independent initialization of SiV0 and NV− within the same optically-addressed volume, and SiV0 emits within the telecoms down-conversion band to 1550 nm: when combined with its high Debye-Waller factor, our initial results suggest that SiV0 is a promising candidate for a long-range quantum communication technology.

Point defects in diamond have attracted considerable interest owing to their application for quantum information processing, communication, and metrology. The most-studied defect, the negatively-charged nitrogen-vacancy (NV−) center, possesses efficient optical spin polarization and spin-state dependent fluorescence, enabling its exploitation as an ultra-sensitive nano-scale magnetic field sensor.1–3 However, the zero phonon line (ZPL) of NV− accounts for only a few percent of its total emission,4 leading to low efficiency in coherent photonic applications. The negatively-charged silicon-vacancy (SiV−) center has also received significant interest as its high Debye-Waller factor (≈ 0.85) makes it an attractive candidate for long-range quantum computation and communication. However, the exceptional optical properties of SiV− are not matched by its spin properties, where a large spin-orbit coupling in the ground state enables phonon-assisted spin-state depopulation, resulting in spin-lattice relaxation-limited coherence lifetimes of 40 ns even at 5 K: efforts are ongoing to overcome this limitation by strain engineering, but currently liquid helium temperatures and below are required to access and readout SiV− spin states.3–5

The neutrally-charged silicon-vacancy (SiV0) has a ground state electron spin \( S = 1 \). Unlike the NV center, where the nitrogen remains covalently bonded to three carbon atoms and the nitrogen-vacancy axis forms a \( C_3 \) axis, the silicon atom in SiV adopts a bond-center location, with a \( D_{3d} \) axis formed by the \( (111) \) joining the split-vacancy [Fig. 1(a)]. SiV0 has been characterized both by electron paramagnetic resonance (EPR)8,9 and optical absorption/photoluminescence (PL)10,11. Similarly to SiV−, the neutral charge state also has a high Debye-Waller factor, with the majority of its photons emitted at the primary zero-phonon line (ZPL) at 946 nm (1.31 eV) [Fig. 1(b)]: this transition has been shown to occur between a \( ^3A_{2g} \) ground state (GS) and \(^3A_{1u}\) excited state (ES)10,11. Quenching of PL at low temperature indicates the presence of a shelving state 5 meV below the ES10. The zero-field splitting (ZFS) in the GS is \( D = +1000 \text{MHz} \) at 300 K.9 The ZFS is highly temperature-dependent, being approximately linear in the range 50–150 K with \( dD/dT = -337 \text{kHz} \text{K}^{-1} \), and an average of \(-202 \text{kHz} \text{K}^{-1} \) between 50 and 300 K — these values are significantly higher than for NV− at \(-74 \text{kHz} \text{K}^{-1} \).12 Finally, non-equilibrium populations of the four symmetry-related defect orientations have been observed in grown-in SiV0 when the diamond crystal is grown on substrates of particular crystallographic orientation.10 This behaviour has been previously observed in NV−13,14 and SiV−.15

We have studied SiV0 in two samples grown by chemical vapor deposition (CVD): silicon was introduced by adding silane to the process gasses during growth. Sample A was grown on a \{100\}-oriented high pressure high temperature (HPHT) substrate, irradiated to a dose of \( 5.4 \times 10^{17} \text{e}^- \text{cm}^{-2} \) at 2.0 MeV and annealed for four hours each at 400 and 800°C to produce 5(2) ppb of SiV0. Sample B was grown on a \{113\}-oriented HPHT...
substrate. The sample was irradiated with 1.5 MeV electrons to a dose of \(1 \times 10^{18} \text{e}^{-} \text{cm}^{-2}\) before annealing for 4 h at 900 °C to produce 75(8) ppb of SiV\(^0\).

To investigate the behavior of SiV\(^0\) under optical excitation, we perform both CW and pulsed EPR measurements (Bruker E580 spectrometer) using a dielectric resonator (Bruker ER 4118X-MD5) and cryostat (Oxford Instruments CF935) for variable temperature measurements. Optical excitation from various laser sources is delivered to the sample via a core fiber held in place with a resinite rod [Fig. 2(a)]. For pulsed measurements the 532 nm laser (CNI MGLII1532) is switched using an acousto-optic modulator. Quantitative EPR measurements are carried out using non-saturating microwave powers.

Figure 2(b) illustrates the effect of in-situ continuous optical pumping at 830 nm on the EPR spectrum of SiV\(^0\). The low- and high-field resonances spin-polarize into enhanced absorption and emission, respectively, under optical pumping. The ZFS of SiV\(^0\) is known to be positive [9] (i.e. \(m_s = \pm 1\) are higher in energy than \(m_s = 0\) at zero magnetic field) and thus the low- and high-field resonances correspond to the \(m_s = 0 \leftrightarrow +1\) and \(m_s = 0 \leftrightarrow -1\) transitions. Therefore, the optical pumping is generating enhanced population in the \(m_s = 0\) state [Fig. 2 inset] — analogous to the polarization behaviour observed in NV\(^-\) when excited with light of wavelength \(\leq 637\) nm. Qualitatively similar polarization is observed in both samples for excitation at 532 (2.33 eV), 830 (1.49 eV) and 915 nm (1.36 eV) at both 80 and 10 K [17]. Given the high Debye-Waller factor of SiV\(^0\) [Fig. 1(b)], it is surprising that spin polarization is generated over such a wide energy range. Photoconductivity measurements of diamond containing SiV\(^0\) indicate a strong photocurrent at 830 nm [18] and hence charge effects are expected to be important for excitation at 830 nm and below: the polarization may therefore be a result of the capture of a hole (electron) at SiV\(^-\) (SiV\(^+\)), and not intrinsic to SiV\(^0\). Theoretical studies indicate that green excitation may also excite from deep valence-band states [11].

We investigate the possibility of an internal spin polarization mechanism by performing a Hahn echo-detected optical frequency-swept measurement: the optical frequency of a widely-tuneable narrow-linewidth laser (TOPTICA CTL 950) is swept over the ZPL, and we detect the resulting EPR enhancement by a two-pulse Hahn echo measurement at each frequency [Fig. 3]. A sharp increase in polarization is observed for resonant excitation at the ZPL (946 nm), confirming a spin-polarization mechanism internal to SiV\(^0\) and unambiguously identifying the 946 nm ZPL with SiV\(^0\). In stark contrast to the behavior of NV\(^-\), polarization is observed even at sub-ZPL energies. Additionally, high-resolution measurements reveal a small ZPL splitting of 0.4 nm (\(\approx 134\) GHz) [Fig. 3 inset]. The origin of this splitting is unclear: optical measurements place the ZPL as a transition between the 946 nm ZPL with SiV\(^0\) and unambiguously identify-
In both samples $\xi$ is found to increase from a typical 0.1% at room temperature to approximately 4% at 80 and 10 K for the same excitation [17]. Maximum bulk polarization of 5.2% is observed at 10 K when pumping with 80 mW at 532 nm; maximum per-photon efficiency is found in sample A under resonant ZPL excitation. At all temperatures and wavelengths the polarization is linear in optical power up to the maximum available at the sample, and therefore we neglect two-photon processes in our analysis.

The increase of $\xi$ with decreasing temperature may arise from several sources: temperature-dependent effects within the intrinsic spin-polarization mechanism itself can alter the polarization efficiency; and increases in electron longitudinal (spin-lattice) lifetime $T_1$ can lead to a greater macroscopic build-up of polarization for the same polarization efficiency. The latter was measured directly using the pulse sequence given in Figure 4(a). The sample was placed in a magnetic field applied within $2^\circ$ of $(111)$ at a field strength of 311–316 mT at 292–10 K: the changes in field are a result of the temperature-dependence of both the microwave resonator frequency and the ZFS. The sample was subjected to a polarizing $5\text{ ms}$ optical pulse to polarize into the $m_s = 0$ state, and an inverting $\pi$ pulse of duration $28\text{ ns}$ was applied to the $m_s = 0 \leftrightarrow +1$ transition, transferring polarization into $m_s = +1$. After a variable delay $\tau$, the remaining spin polarization was measured using a Hahn echo detection sequence: this yields an exponentially-decaying signal with a single time constant equal to the longitudinal lifetime $T_1$ [Fig. 4(b)]

The measured $T_1$ for SiV$^0$ in sample B are highly temperature-dependent [Fig. 4(c)]; unlike NV$^-$, which retains $T_1 \sim \text{ms}$ at room temperature, SiV$^0$ lifetimes in this sample decrease from approximately 25 s at 15 K to 80 $\mu$s at room temperature. EPR linewidth broadening is observed above room-temperature [17], and can be used as an indirect measure of $T_1$ in the limit that $T_2 \leq 2T_1$ [23], indicating $1/T_1 \gtrsim 1\text{ MHz}$. The dramatic temperature-dependence of $T_1$ is expected to account for the poor polarization efficiencies observed at room temperature. Interpretation of spin-lattice lifetimes in solids typically performed in terms of contributions from different phonon processes [24]. Interactions with single phonons (the so-called direct process, $1/T_1 \propto T$) can be neglected, as the spin energies involved at X-band $T = 10\text{ GHz}/k_B = 0.5\text{ K}$ are at least an order of magnitude lower than the lowest measurement temperature (11 K). Relaxation via two phonons of different energies — a Raman process — can occur if the energy difference is equal to the spin transition energy, and takes the form $1/T_1 \propto T^n$ where $n \in \{5, 7, 9\}$ depending on the spin levels involved, with $n = 7$ typical for a non-Kramers doublet [24, 25]. Finally, the Orbach process describes interaction with an excited spin state at a phonon-accessible energy $\Delta E$ above the ground state: the spin is excited by absorption of a phonon of energy $\hbar \Omega_n = \Delta E$ and relaxes to a different ground spin state by emission of a phonon $\hbar \Omega_e \neq \Delta E$. The $T_1$ data were therefore phenomenologi-
cally modeled using
\[
\frac{1}{T_1} = A_{\text{const}} + A_{\text{Raman}} T^7 + A_{\text{Orbach}} \frac{\Delta E/E_{\text{Raman}}}{k_B T} - 1.
\]

The fit in Figure 4(c) was generated using the coefficients
\[
A_{\text{const}} = 0.036 \text{s}^{-1}, \quad A_{\text{Raman}} = 5.0 \times 10^{-13} \text{s}^{-1} \text{K}^{-7},
\]
\[
A_{\text{Orbach}} = 1.5 \times 10^5 \text{s}^{-1} \text{and} \Delta E = 22 \text{meV}.
\]
The energy \(\Delta E = 22 \text{meV}\) matches the phonon sideband observed in the echo-detected PLE measurement [Fig. 3] and is close to the dominant phonon frequency \(\hbar \Omega = 28 \text{meV}\) estimated from optical absorption measurements [10]; we therefore conclude that the primary phonon coupling frequency is similar in both the ground and excited states. Multifrequency measurements would enable confirmation of the involved \(T_1\) processes via their magnetic field dependence [24].

The spin coherence time, \(T_2\), is a critical parameter for many applications in sensing and quantum computation [26, 27]. We measure the \(T_2\) directly using a Hahn echo-decay sequence (\(\pi/2 - \tau - \pi - \tau - \pi - \tau - \pi\) echo) [25], and find that \(T_2\) changes from 2.0 \(\mu\text{s}\) at room temperature to 103 \(\mu\text{s}\) at 27 K [Fig. 3]. At both 292 and 96 K, we find \(T_2 \approx T_1\), confirming that we are in the limit \(T_2 \leq 2T_1\) [23]: at 27 K, \(T_2 = 103 \mu\text{s}\) is limited by spin-spin interactions rather than \(T_1 = 82 \mu\text{s}\). This value is comparable to \(T_1\), where ensemble measurements reach 630 \(\mu\text{s}\) without the use of decoupling sequences [28].

We now consider the source of the spin polarization. In NV\(^-\), the electronic structure relevant to spin polarization is described by the molecular orbitals (MO) \(a_1\) and \(e_2\) with the \(3A_2\) GS generated by the configuration \(a_1^2e_2^2\) [29]. Spin polarization occurs by intersystem crossing (ISC) from the \(3E\) ES (\(a_1^1e_2^3\)) into a pair of singlets (\(1A_1, 1E\)) arising from the same orbital configuration as the GS [30]. In SiV\(^-\), the \(2A_{2g}\) GS is described by the MO configuration \(a_1^2a_2^2e_2^2\), which also produces two singlet states \(1A_{1g} \& 3E_g\). The configuration \(a_1^2a_2^2e_2^2\) is responsible for the \(3A_1u\) ES and additional states \(1A_{1u}, 1A_{2u}, 1E_u, 3A_{2u}\) and \(3E_u\). The multitude of available states suggests the possibility of spin-orbit (SO) mediated ISC mechanisms, similar to NV\(^-\) and other defects in diamond and SIC [31]: any model for SiV\(^0\) must account both for PL quenching at low temperature [10] and spin polarization generated by sub-ZPL excitation. Two of the possible energy level schemes which are consistent with experiment are given in Figure 6 both based on ISC between singlet and triplet states. Sub-ZPL polarization is generated in (a) by pumping directly into the singlet state, which becomes weakly-allowed due to SO effects in the ground state. In (b), no-phonon dipole transitions from the \(3A_{2g}\) GS to the \(3A_{2u}\) ES are forbidden, but transitions into the vibronic sideband would be possible by emission of an \(A_{2g}\) phonon. Such an absorption would have no ZPL and the broad band may be difficult to detect. In this model, the spin polarization is generated by ISC from the \(3A_{2u}\) triplet to a singlet (\(1E_u\)), and not from the ES involved in the 946 nm ZPL. Resonant excitation to the \(3A_{1u}\) level would nevertheless result in spin polarization via non-radiative transitions from \(3A_{1u}\) to \(3A_{2u}\). In both models, transitions between the singlet states must be dipole forbidden in order for the upper state to be an effective shelving state [10]. Detailed calculation of level energies and ordering is beyond the scope of the present work; nevertheless, the model emphasises that there are different possible polarization mechanisms.
low (<830 nm \[18\]), additional mechanisms are expected to occur: further work is required to understand the electronic structure and spin polarization mechanism of SiV\(^0\).

Bulk spin polarization and long spin lifetimes at 30 K and below, combined with a high Debye-Waller factor and infrared emission, establish SiV\(^0\) as a defect which demands further study. In particular, optical stress measurements would unambiguously identify the excited state of the 946 nm ZPL and in turn aid in the interpretation of the observed echo-detected 134 GHz ZPL splitting. Additionally, demonstration of spin-dependent photoluminescence contrast would enable the rapid determination of center properties and enable its exploitation as e.g. a remote temperature sensor. The ability to efficiently spin-polarize SiV\(^0\) at wavelengths which do not affect NV\(^-\) opens the possibility of protocols which use NV\(^-\) as a control/readout mechanism but where multiple qubits can be initialized independently of the NV\(^-\) center and within the same optically-addressed volume. The 946 nm wavelength falls within the 980 nm band, where downconversion to the telecoms 1550 nm wavelength has already been demonstrated \[32\]: if future studies detect ODMR from SiV\(^0\) then it will be a compelling candidate for long-range quantum communication networks.

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Supplemental Material

CALCULATION OF BULK SPIN POLARIZATION PERCENTAGE

When considering the spin polarization of the $^3A_2$ triplet ground state it is necessary to examine the spin populations of the $m_S = 0$ and $\pm 1$ spin levels. The fractional spin population of the $i^{th}$ level is given by

$$p_i = \frac{N_i}{N}$$  \hspace{1cm} (S1)

where $N_i$ denotes the number of spins in the $i^{th}$ spin level and $N$ is the total number of spins in the triplet state. For a three level system,

$$p_{+1} + p_0 + p_{-1} = 1$$  \hspace{1cm} (S2)

where $p_{+1}$, $p_0$ and $p_{-1}$ are the fractional populations of the $m_S = +1$, 0 and $-1$ levels, respectively. The EPR signal intensity is proportional to the population difference between levels

$$\eta_{i+1,0} = p_0 - p_{+1}$$  \hspace{1cm} (S3)

$$\eta_{0,-1} = p_{-1} - p_0$$  \hspace{1cm} (S4)

In the absence of optical pumping the population of the $i^{th}$ spin level is given by Boltzmann statistics according to

$$p_i = \frac{e^{-E_i(B)/k_BT}}{\sum_{i=1}^{N} e^{-E_i(B)/k_BT}}$$  \hspace{1cm} (S5)

where $E_i(B)$ is the energy of the $i^{th}$ spin level in a magnetic field $B$, $k_B$ is the Boltzmann constant, $T$ is the sample temperature and $N$ is the total number of spin states.

Optical pumping induces spin polarization and hence the occupation probabilities are no longer in thermal equilibrium (i.e. non-Boltzmann). It is possible to calculate the difference in the occupation probabilities under illumination by considering the experimentally determined intensities of the low and high field resonance lines:

$$\eta^l_{d} = \eta^d_{d} \frac{I^l_{d}}{I^d_{d}}$$  \hspace{1cm} (S6)

where $d$ and $l$ refer to the sample in the dark and light, respectively. $I$ is positive if the transition is in absorption and negative if the transition is in emission. However, Eq. [S6] only applies when the transitions are not microwave-power saturated: in our experiments it was not possible to measure in non-saturated conditions at 10 K due to the long spin $T_1$. The unsaturated value for $I^d_{d}$ ($I^d_{d}$ at temperature $T$) was instead calculated using the following relationship, based on the experimental value for $I^d_{RT}$ ($I^d_{RT}$ at room temperature) and the theoretical occupation probability difference between the spin levels at the different temperatures in the dark:

$$I^d_{T} = I^d_{RT} \frac{\eta^d_{RT}}{\eta^d_{RT}}$$  \hspace{1cm} (S7)

Solving for the occupation probabilities of the $m_S = +1$, 0 and $-1$ spin levels under optical illumination one finds

$$p_{+1}' = \frac{1}{3} \left[ 1 + 2 \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{+1,0} - \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{0,-1} \right]$$  \hspace{1cm} (S8)

$$p_{0}' = \frac{1}{3} \left[ 1 + \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{+1,0} - \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{0,-1} \right]$$  \hspace{1cm} (S9)

$$p_{-1}' = \frac{1}{3} \left[ 1 + \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{+1,0} + 2 \left( \eta^d_{RT} \frac{I^l_{T}}{I^d_{RT}} \right)_{0,-1} \right]$$  \hspace{1cm} (S10)
The degree of optical spin polarization $\xi$ is defined as

$$
\xi = \frac{p_{l0} - p_{d0}}{p_{d1} + p_{d-1}}
$$

(S11)

Thus, $\xi = 100\%$ occurs when all the spins are in the $m_S = 0$ spin level and $p_{l0} = p_{d1} + p_{d0} + p_{d-1}$, with all values calculated at the same temperature $T$. At the other extreme, when $p_{l0} = p_{d0}$ the system is not optically spin polarised and $\xi = 0\%$.

**BROADENING OF EPR LINEWIDTH AT HIGH TEMPERATURE**

At elevated temperatures (above approximately 300 K), significant broadening of the EPR linewidth of SiV$^0$ is observed [Fig. S1]. The linewidth can be used as an indirect measurement of $T_1$ in the limit that $T_2$ is $2T_1$-limited [S1]. The method is indirect as the linewidth also includes contributions from e.g. unresolved hyperfine couplings to distant $^{13}C$, which will broaden the line without affecting $T_1$. The linewidth-derived data included in Fig. 4(c) of the main text have been obtained as follows:

- Data were fit to extract raw linewidth in mT at each temperature
- Linewidth was converted to MHz using $\gamma_e = 28.025$ MHz mT$^{-1}$
- At room temperature, $T_2 = 900$ ns is within a factor of 4 of $2T_1 = 3.9$ µs (256 kHz) and $T_1$ is changing rapidly. Therefore we assume that at temperatures of 300 K and above, $T_2$ is limited by $2T_1$.
- All linewidth data are offset by $-250$ kHz so that the directly-measured $T_1$ and linewidth-derived values match at room temperature: this offset is reasonable, as typical linewidths due to unresolved $^{13}C$ couplings are of the order of 700 kHz [S2], and will increase the derived $1/T_1$ value.

**FIG. S1.** (a) Measured SiV$^0$ spectra of the $m_S = 0 \leftrightarrow 1$ transition at 292 and 490 K with the magnetic field $B \parallel \langle 1 1 0 \rangle$. The high temperature spectrum has been scaled for clarity. (b) Temperature-dependence of SiV$^0$ linewidth above room temperature, showing significant broadening at elevated temperatures.

**POLARIZATION COMPARISONS**

Both samples A & B were measured using CW EPR at four different wavelengths and two different temperatures. The results are given in [S2]. It is clear that there are differences in the polarization efficiency at different wavelengths between the two samples, specifically the marked difference in behaviour at the higher energy (830 and 532 nm) and lower energy (915 and 946 nm excitation): as 830 nm (1.4 eV) is the threshold for photocurrent from SiV$^0$ [S3], it seems likely that the two samples are undergoing different degrees of charge transfer. Nevertheless, the visibility of polarization at all wavelengths suggests either direct pumping into a higher-energy state which decays into the spin-polarization path, or that ionization of SiV$^-$/SiV$^+$ can directly produce SiV$^0$ in a spin-polarized state. The situation is complicated by below-ZPL spin polarization [Fig. 3, Fig. S3], further investigation is required to understand the spin polarization and charge transfer behavior of this system.
FIG. S2. Raw CW EPR spectra for both samples at different temperatures and under optical excitation from different wavelengths. Available optical power was kept constant at both temperatures for each sample, but was different between samples due to experimental constraints. In all measurements the spin polarization was linear in optical power. Spectra have been offset in magnetic field for clarity. The asymmetric lineshapes visible at 10 K under excitation at 915 and 946 nm are due to microwave saturation of the transition: the same effect (a result of long $T_1$ at these temperatures in the absence of optical excitation) prohibited collection of dark reference spectra at low temperature. Bulk spin polarization values ($\xi$) have been given for spectra which are unsaturated — they have not been normalized in any way.

FIG. S3. CW-detected EPR measurements of the high-field (emission) line of sample A. The applied magnetic field is static, and the intensity of the $m_S = 0 \leftrightarrow -1$ transition is monitored as a function of time, with the laser switched manually on and off every 10 s. Two scans are shown, corresponding to ZPL-resonant (946.4 nm) and above-ZPL excitation.

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